Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	3733	(lens near material) and lens.ab.	USPAT	OR	OFF	2004/09/01 21:59
S2	7	BOETTIGER.in. and ULRICH	USPAT	OR	OFF	2004/09/01 21:25
S3	5	(BOETTIGER.in. and ULRICH) and lens	USPAT	OR	OFF	2004/09/01 21:25
S4	4	BOETTIGER.in. and ULRICH	US-PGPUB	OR	OFF	2005/03/03 13:25
S5	178	((lens near material) and lens.ab.) and wafer	USPAT	OR	OFF	2004/09/01 21:59
S6	109	((lens near material) and lens.ab.) and (wafer with lens)	USPAT	OR	OFF	2004/09/02 18:31
S7	832	lens near2 semiconductor	USPAT	OR	OFF	2004/09/02 18:31
S8	279	lens near semiconductor	USPAT	OR	OFF	2004/09/02 20:27
S9	143	(lens near semiconductor) and lens.ab.	USPAT	OR	OFF	2004/09/02 21:32
S10	63	(lens near semiconductor) and mask	USPAT	OR	OFF	2004/09/02 18:32
S11	24	(lens near semiconductor) and lens.ab. and mask	USPAT	OR	OFF	2004/09/02 19:12
S12	51	(lens with semiconductor) and lens.ab. and mask and micro$1lens	USPAT	OR	OFF	2004/09/02 19:12
S13	16	(lens with semiconductor) and lens.ab. and (mask same micro$1lens)	USPAT	OR	OFF	2004/09/02 19:12
S14	40	lens near semiconductor and method and (coat$3 and expos$3 and remov$4)	USPAT	OR	OFF	2004/09/02 21:32
S15	40	(lens near semiconductor) and method and (coat$3 and expos$3 and remov$4)	USPAT	OR	OFF	2004/09/02 20:33
S16	9	(lens near semiconductor) and lens.ab. and lithographic and mask	USPAT	OR	OFF	2005/03/03 13:57
S17	27	(lens near10 semiconductor) and lens.ab. and lithographic and mask and array	USPAT	OR	OFF	2004/09/02 21:33
S18	1	359/618,621,623.ccls. and (lens near10 semiconductor) and lens.ab. and lithographic and mask and array	USPAT	OR	OFF	2005/03/03 19:52

S19	18	("4326800" | "4490039" | "5233174" | "5463649" | "5493391" | "5539718" | "5610897" | "5825476" | "5828455" | "5864381" | "5912731" | "5936720" | "5936739" | "5939716" | "5978085" | "6052180" | "6130419" | "6184974").PN.	USPAT	OR	OFF	2004/09/02 21:42
S20	2	430/321,396.ccls. and (lens near10 semiconductor) and lens. ab. and lithographic and mask and array	USPAT	OR	OFF	2004/09/03 13:27
S21	0	430/1,2,4,5,6.ccls. and (lens near10 semiconductor) and lens. ab. and lithographic and mask and array	USPAT	OR	OFF	2004/09/07 17:59
S22	433	430/11,5,30.ccls. and lens and lithographic and mask	USPAT	OR	OFF	2005/03/03 19:51
S23	42	430/11,5,30.ccls. and (lens near10 semiconductor) and lithographic and mask	USPAT	OR	OFF	2004/09/07 18:54
S24	1	430/11,5,30.ccls. and (lens near10 semiconductor) and lithographic and mask and (mask same pull$1back)	USPAT	OR	OFF	2004/09/07 18:01
S25	17	430/296,311,320,321.ccls. and (lens near10 semiconductor) and lithographic and mask	USPAT	OR	OFF	2005/03/03 20:03
S26	3	257/432,98.ccls. and (lens near10 semiconductor) and lithographic and mask	USPAT	OR	OFF	2005/03/03 20:04
S27	8	Ulrich and Boettiger.in.	USPAT	OR	OFF	2005/03/03 12:45
S28	10	Ulrich and Boettiger.in.	US-PGPUB	OR	OFF	2005/03/03 13:26
S29	1	Ulrich and Boettiger.in. and reflow and first and focal and length and second and radius	US-PGPUB	OR	OFF	2005/03/03 13:27
S30	65	lens.ab. and lithographic and semiconductor and (lens$ same (hole$1 or cut$1out))	USPAT	OR	OFF	2005/03/03 15:36
S31	33	lens.ti. and lithographic and semiconductor and (lens with shape)	USPAT	OR	OFF	2005/03/03 15:36
S32	17	430/11,5,30.ccls. and lens and lithographic and (lens same hole)	USPAT	OR	OFF	2005/03/03 19:52
S33	498	430/11,5,30.ccls. and lens and lithographic	USPAT	OR	OFF	2005/03/03 20:04
S34	661	359/618,621,623.ccls. and lens	USPAT	OR	OFF	2005/03/03 20:03

S35	1119	430/296,311,320,321.ccls. and lens	USPAT	OR	OFF	2005/03/03 20:03
S36	99	430/296,311,320,321.ccls. and lens and semiconductor and radius	USPAT	OR	OFF	2005/03/03 20:03
S37	153	359/618,621,623.ccls. and lens and radius	USPAT	OR	OFF	2005/03/03 20:03
S38	110	359/618,621,623.ccls. and lens and radius and focal and length	USPAT	OR	OFF	2005/03/03 20:04
S39	59	359/618,621,623.ccls. and lens and radius and focal and length and convex	USPAT	OR	OFF	2005/03/03 20:04
S40	18	430/11,5,30.ccls. and lens and lithographic and radius and focal and length	USPAT	OR	OFF	2005/03/03 20:05
S41	2	257/432,98.ccls. and (lens and semiconductor) and lithographic and focal and radius and length	USPAT	OR	OFF	2005/03/03 20:05